


<b>Search Notes</b>  	<b>Application/Control No.</b>  10594338	<b>Applicant(s)/Patent Under Reexamination</b>  MIWA ET AL.
	<b>Examiner</b>  Lisa Chau	<b>Art Unit</b>  1794

<b>SEARCHED</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>
428	682.1 and 693.1	1/11/10	LC

<b>SEARCH NOTES</b>		
<b>Search Notes</b>	<b>Date</b>	<b>Examiner</b>
Inventors	1/11/10	LC
Assignee	1/11/10	LC
Foreign	1/11/10	LC
Update	6/15/10 1/26/11 10/5/11	LC

<b>INTERFERENCE SEARCH</b>			
<b>Class</b>	<b>Subclass</b>	<b>Date</b>	<b>Examiner</b>

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